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APPLICANT: **Yasuhisa FUJII, et al.**	
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U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes-Number-Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation Yes	Translation No
JMS		JP 10-74762	03/17/1998	ULVAC JAPAN LTD		(Japan w/English Abstract)	
		JP P2000-306996A	11/02/2000	NEC CORP		(Japan w/English Abstract)	
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OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.
MH		"Stress-Induced Voiding Under Vias Connected To Wide Cu Metal Leads", by E.T. Ogawa et al., IEEE 02CH37320 40th Annual International Reliability Physics Symposium, Dallas, Texas, 2002, pp. 312-321

EXAMINER	DATE CONSIDERED
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